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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 4559**
Yasushi ISAYAMA et al. : Docket No. 2003_1051
Serial No. 10/627,684 : Group Art Unit 1742
Filed July 28, 2003 : Examiner Harry Wilkins

METHOD OF MEASURING THE
CONCENTRATION OF A LEVELER IN A
PLATING LIQUID, AND METHOD OF AND
APPARATUS FOR MANAGING A PLATING LIQUID

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975

In response to the Restriction Requirement of August 22, 2005, Applicants hereby elect the invention of Group I, claims 1 and 2, drawn to a method of managing a plating liquid by sampling, without traverse, for further prosecution. In view of this election, a full examination on the merits of the present application is respectfully requested.

Respectfully submitted,

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